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**From:** Ex. 4 CBI  
**Sent:** 7/29/2017 3:48:11 PM  
**To:** Bauer, Jeff [Bauer.Jeff@epa.gov]  
**Subject:** 2 uses EPA seems to have inadvertently left off the CO

Jeff,  
*Two uses that were requested in PMN P-14-0627 as amended and appear to have been inadvertently left out of the draft consent order are "Silicone Wafer Cleaning in Clean Rooms" (Proc 2a) and "Photoresist Stripping in Microelectronics in Clean Rooms" (Proc 2aa Use 2a).* Ex. 4 CBI  
Ex. 4 CBI *Please include these in the consent order being updated (i.e. to include these two uses).*

**Ex. 4 CBI**

Best regards,

**Ex. 4 CBI**